IN THE SPECIFICATION

Please amend the heading at page 11, line 15, as follows:

DETAILD-DETAILED DESCRIPTION

Please amend the paragraph at page 22, lines 15-23, as follows:

That is, as [[an]] a field intensity acting as actions of transporting and hopping, [[an]] a field intensity in the vicinity of the base plate, which decides an initial speed becomes important to a toner particle on the transporting base plate. In other words, wards, after a toner separates from the vicinity of the surface of the base plate, even when the voltage applied to the electrode rises and the field intensity increases, the field intensity does not contribute to an action of transporting or hopping, which results in lowering of efficiency.

Please amend the paragraph at page 28, line 24 to page 29, line 9, as follows:

Also, as another anther example, using a polyimide base film (with a thickness of 20 to 100μm) as the base member (supporting base plate 11), it is possible to employ a film of Cu, SUS or the like with a thickness of 10 to 20μm to the base member as electrode material. In this instance, polyimide is coated on a metal material in a thickness of 20 to 100μm by a roll coater and baked. Thereafter, the metal material is patterned in a shape of the electrodes 12 by a photolithography process and an etching process, and polyimide is coated on the surfaces of the electrodes 12 as the protective layer 13. When there is undulation corresponding to the thickness of 10 to 20μm of the metal material electrode, the transporting base plate is completed by flattening the protective layer 13.